Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	32024	(PECvD or HDPCvD or ((Cvd or (chemical adj vapor\$6 adj deposit\$6)) near5 (plasma or PE or HDP))) same (dielectric or insulat\$6 or SiCO or SiOC or ((Silicon or Si or silicate or silane or siloxane) near5 (oxide or dioxide or oxycarbide or hydrocarbon or carbon or methyl or dimethyl or dimethoxy or dimethoxysilane or DMDMOS or "DM-DMOS")) or (Si?sub\$3 near3 C?sub\$3 near3 O?sub\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:58
L2	4875	1 and (situ or insitu or ("same" adj (chamber or reactor or processor or apparatus)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:55
L3	26000	1 and (@ad<="20020909" or @rlad<="20020909")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:56
L4	4744	1 and ((RF or power) near15 (decreas\$6 or reduc\$6))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:57
L5	858	2 and 3 and 4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:57
L6	536	(PECvD or HDPCvD or ((Cvd or (chemical adj vapor\$6 adj deposit\$6)) near5 (plasma or PE or HDP))) same ((RF or power) near15 (decreas\$6 or reduc\$6))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:58
L7	18082	(dielectric or insulat\$6 or SiCO or SiOC or ((Silicon or Si or silicate or silane or siloxane) near5 (oxide or dioxide or oxycarbide or hydrocarbon or carbon or methyl or dimethyl or dimethoxy or dimethoxysilane or DMDMOS or "DM-DMOS")) or (Si?sub\$3 near3 C?sub\$3 near3 O?sub\$3)) same ((RF or power) near15 (decreas\$6 or reduc\$6))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:59

L8	372	5 and (6 or 7)	US-PGPUB;	OR	ON	2005/11/03 16:59
			USPAT;			
			EPO; JPO;			
			DERWENT;			
			IBM_TDB			

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L20	31845	(PECvD or HDPCvD or ((Cvd or (chemical adj vapor\$6 adj deposit\$6)) near5 (plasma or PE or HDP))) same (dielectric or insulat\$6 or SiCO or SiOC or ((Silicon or Si) near5 (oxide or dioxide or oxycarbide or hydrocarbon or carbon or methyl)) or (Si?sub\$3 near3 C?sub\$3 near3 O?sub\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:09
L41	56426	(dielectric or insulat\$6 or SiCO or SiOC or ((Silicon or Si or silicate or siloxane) near5 (oxide or dioxide or oxycarbide or hydrocarbon or carbon or methyl or dimethyl or dimethoxy)) or (Si?sub\$3 near3 C?sub\$3 near3 O?sub\$3)) same (CMP or polish\$6)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:08
L46	24	(dielectric or insulat\$6 or SiCO or SiOC or ((Silicon or Si or silicate or siloxane) near5 (oxide or dioxide or oxycarbide or hydrocarbon or carbon or methyl or dimethyl or dimethoxy)) or (Si?sub\$3 near3 C?sub\$3 near3 O?sub\$3)) with (hardness or mechanical or strength) with (gigapascal or (giga adj pascal))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:29
L47	6	46 and 41 and 20 and (@ad<="20020909" or @rlad<="20020909")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:29

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L20	31845	(PECvD or HDPCvD or ((Cvd or (chemical adj vapor\$6 adj deposit\$6)) near5 (plasma or PE or HDP))) same (dielectric or insulat\$6 or SiCO or SiOC or ((Silicon or Si) near5 (oxide or dioxide or oxycarbide or hydrocarbon or carbon or methyl)) or (Si?sub\$3 near3 C?sub\$3 near3 O?sub\$3))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:09
L40	255	(dielectric or insulat\$6 or SiCO or SiOC or ((Silicon or Si or silicate or siloxane) near5 (oxide or dioxide or oxycarbide or hydrocarbon or carbon or methyl or dimethyl or dimethoxy)) or (Si?sub\$3 near3 C?sub\$3 near3 O?sub\$3)) with (hardness or mechanical or strength) with GPa	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:06
L41	56426	(dielectric or insulat\$6 or SiCO or SiOC or ((Silicon or Si or silicate or siloxane) near5 (oxide or dioxide or oxycarbide or hydrocarbon or carbon or methyl or dimethoxy)) or (Si?sub\$3 near3 C?sub\$3 near3 O?sub\$3)) same (CMP or polish\$6)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:08
L42	94	40 and 41	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:08
L43	53	42 and 20	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:09
L44	33	43 and (@ad<="20020909" or @rlad<="20020909")	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/11/03 16:09